



30/C Amdt  
8/29/02  
A. Waller

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE  
Application Serial No. .... 09/059,644  
Filing Date ..... April 13, 1998  
Inventor ..... Pai-Hung Pan  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2822  
Examiner ..... M. Trinh  
Attorney's Docket No. .... MI22-898  
Title: Semiconductor Processing Methods of Forming a Conductive Gate  
and Line

**RESPONSE TO MAY 8, 2002 OFFICE ACTION**

To: Box Fee Amendment  
Assistant Commissioner for Patents  
Washington, D.C. 20231

From: Frederick M. Fliegel, PhD  
Tel. 509-624-4276; Fax 509-838-3424  
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601 W. First Avenue, Suite 1300  
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RECEIVED  
AUG 20 2002  
TECHNOLOGY CENTER 2800

Sir:

Responsive to the Office Action dated May 8, 2002, Applicant  
amends and remarks as follows.

08/14/2002 NMOHAMM1 00000131 09059644

01 FC:103	162.00 OP
02 FC:102	420.00 OP